CORRECTION

Correction to: Formation of microstructures on Ni film surface by nanosecond laser irradiation

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The original version of this article unfortunately contained mistakes.

On the pages 2, 3 and 5 the values of the fluence (0.5 and 0.1 J/cm²) are incorrect. The correct values are 5 and 10 J/cm².

The original article can be found online at <https://doi.org/10.1007/s00339-018-1635-0>.

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